

STD LSNitride2 5/9/2018	OLD RECIPE
Date	5/9/18
Standard LS Nitride2 Coat	
Coat time, min	10
Standard LS Nitride2 Deposition	
Deposition time, min	30
LF power setup, W	80
RF power setup, W	30
Pressure, mTorr	800
Gas flow, sccm	
2%SiH	520
NH3	17
N2	980
T, C	~300
Thickness, nm	237.22
Dep.rate, nm/min	7.91
Index at 632.8nm	1.987
Index at 1550nm	1.946
Stress, MPa	477.48
BHF, nm/min	37.54
Std. clean, min	40

